

(19)



Europäischer Patentamt
European Patent Office
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(11)



EP 1 130 381 A1

(12)

EUROPEAN PATENT APPLICATION

(43) Date of publication:

05.09.2001 Bulletin 2001/36

(51) Int Cl.7: G01N 21/53, C02F 1/32

(21) Application number: 00301783.7

(22) Date of filing: 03.03.2000

(84) Designated Contracting States:

AT BE CH CY DE DK ES FI FR GB GR IE IT LI LU
MC NL PT SE

Designated Extension States:

AL LT LV MK RO SI

(71) Applicant: Hanovia Limited

Slough, Berkshire SL1 4XB (GB)

(72) Inventor: Hamilton, David

Slough, Berkshire SL1 4XB (GB)

(74) Representative: Granleese, Rhian Jane

Marks & Clerk,
57-60 Lincoln's Inn Fields
London WC2A 3LS (GB)

Remarks:

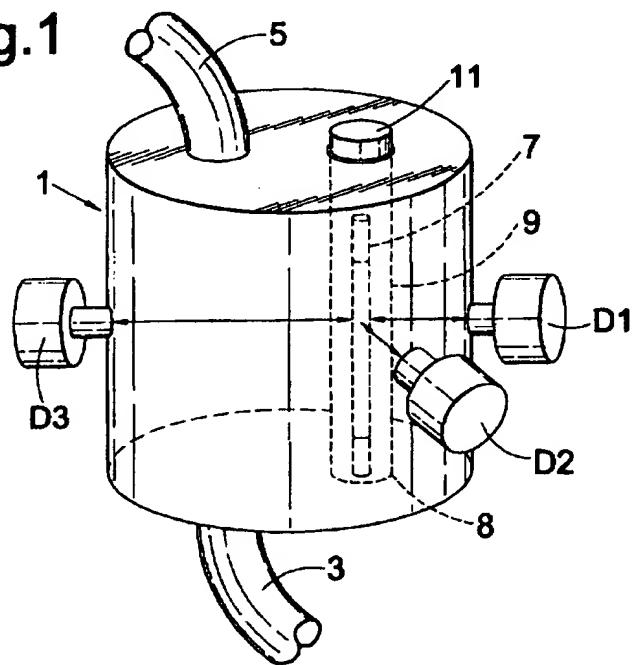
A request for correction has been filed pursuant to Rule 88 EPC. A decision on the request will be taken during the proceedings before the Examining Division (Guidelines for Examination in the EPO, A-V, 3.).

(54) Transmission meter, a method of measuring transmittance and a disinfection apparatus

(57) A transmission meter (1) and a method for measuring the transmittance of a fluid, the meter (1) comprises an analysis chamber for passage of the fluid therethrough, means for receiving an electromagnetic source (9) within said chamber and three sensors (D1, D2 and D3) each configured to measure the output from

said source (9), wherein each of the three sensors (D1, D2 and D3) are located at different distances from the source (9). The transmission meter may be used in a disinfection system either to measure the transmittance of the untreated water or to measure the transmittance of the water as it is purified.

Fig.1



Description

[0001] The present invention relates to the field of transmission meters and methods for measuring the transmittance of fluids. More specifically, the present invention relates to a transmission meter and method for measuring the transmittance of a fluid, such as water, in a sterilisation or disinfection apparatus.

[0002] Ultraviolet (UV) disinfection equipment works by irradiating the fluid to be purified, with radiation having wavelengths predominantly in the range from 240 to 280 nm. Such UV disinfection equipment has many uses such as treating the domestic and public water supplies, water supplies for the process industry, sewage effluent, and any applications where the presence of pathogens may be injurious to health. Therefore, satisfactory disinfection must be achieved in order to safeguard the health of the public.

[0003] To achieve satisfactory disinfection of the liquid, it is important to know the rate of fluid flow, the UV intensity within the disinfection chamber and the fluid transmittance at the wavelength of the UV radiation. Knowing the above will allow the performance of the disinfection equipment to be continuously monitored, and, if necessary, corrective action can be taken if the levels fall below predefined limits.

[0004] The flow rate can be easily measured by well known techniques. The UV intensity within the disinfection or purification chamber can also be measured by placing a UV sensor in the chamber. The transmittance of a fluid is generally measured by placing a radiation source in the fluid to be measured and measuring the intensity of the detected radiation at a point distant from the source. The transmittance can be easily calculated if the power of the source, the distance of the detector from the source is known and that there is no other obstruction between the source and the detector.

[0005] The problem arises when the sensor is required to monitor the transmittance of a continuously or intermittently flowing fluid over a long time, for example, a few days, weeks, months, even years. A single UV sensor will be able to sense a decrease in the intensity of the light from the UV source over time. However, it will not be able to establish if this is due to the output of the source decreasing over time or, the transmittance of the fluid itself changing. Another factor which will affect the measured intensity is so-called photochemical fouling which occurs due to the fluid depositing particles, especially iron and manganese compounds, on the source and optic surfaces of the sensor.

[0006] Previous attempts to address the above problems have included a meter with a detector which is moveable between two positions as described in NL1003961 and a meter with two fixed detectors at different distances from the source as described in JP 10057.

[0007] To address the above problems, a first aspect of the present invention provides a transmission meter

for measuring the transmittance of a fluid, the meter comprising:

5 a chamber for the flow of fluid therethrough;
means for receiving an electromagnetic source within said chamber; and
three sensors each configured to measure the output from said source,
wherein each of the three sensors are located at different distances from the source.

[0008] The three sensors allow detection of the intensity of the emitted radiation at three different points. The intensity detected at each of the sensors will be dependent on the irradiance of the source, the transmittance of the fluid, the distance of the source from the sensor and the extent of deposition on the optic surfaces of the apparatus. As the distance of each of the sensors from the source is known, it is possible to establish the transmittance of the fluid. More than three sensors could be used if required.

[0009] Preferably, the sensors all measure the irradiance from the same part of the source. This eliminates errors due to the irradiance of the source varying across its output surface and variations in photochemical fouling of the source. To obtain accurate readings, it is preferable if the sensors are at significantly different distances from the source. For example, preferably, the distances of the two sensors which are furthest from the source are substantially integral multiples of the distance of the closest sensor to the source.

[0010] As previously mentioned, the meter is primarily intended for use in a disinfection apparatus. Therefore, in a second aspect, the present invention provides a disinfection apparatus comprising a transmission meter and a purification chamber, said purification chamber being capable of receiving an electromagnetic source for purifying fluid passing through said purification chamber, said meter comprising an analysis chamber for passage of the fluid therethrough, means for receiving an electromagnetic source within said analysis chamber and three sensors each configured to measure the output from said source within the analysis chamber, wherein each of the three sensors are located at different distances from the source.

[0011] Preferably, the transmission meter is located upstream from the purification chamber. Thus, it is used to measure the transmittance of the fluid prior to treatment. This can be achieved by directing a fraction of the fluid in the inlet pipe to the purification chamber into the transmission meter.

[0012] In many instances, there will be more than one purification chamber. The plurality of purification chambers will preferably be provided in a parallel arrangement as opposed to a series arrangement.

[0013] The data collected by the three sensors in the analysis chamber can be analysed remote from the meter. For example, the sensors could each have means

to transmit the data from the meter to a remote analyser, or, the meter could be provided with data storage means for periodic collection by a computer via a hardwire or wireless link or even manually by an operator.

[0014] Alternatively, the meter may comprise analysis means to compare the output of the three sensors. The analysis means could output an electrical signal which is related to the transmittance of the fluid. This electrical signal could either be analogue or digital in character.

[0015] Preferably, the meter or the disinfection system comprises control means into which the output from the analysis means is fed. The control means may be used to control the meter to perform calibration or self cleaning functions. Alternatively, the control means may be used to adjust the parameters of the purification chamber to maintain treatment levels within acceptable limits. Typically, there is a predefined minimum level for the treatment level of the chamber.

[0016] For example, the control means could be used to increase the power supplied to the radiation source or sources within the purification chamber. In the case where there are many purification chambers provided in parallel, the control means can be used to bring on line or switch fluid away from one or more of the chambers i.e. it can be used to control the number of chambers in use at any one time.

[0017] The knowledge of the transmittance of the fluid allows the level of treatment required by the fluid to be accurately computed.

[0018] To perform the cleaning and/or calibration functions, the meter preferably further comprises valve means configured to switch the supply of fluid into the chamber between at least two different sources. The two sources are preferably a source containing the fluid which is to be measured and a source containing de-ionised water which has virtually 100% transmission at UV wavelengths. UV wavelengths are typically between 200nm and 400nm, and more specifically from 240nm to 280nm.

[0019] More preferably, the meter further comprises valve means which are capable of switching between three sources. The sources are preferably, the fluid which is to be treated, a de-ionised water source and a source of weak acid. The weak acid supply is used to clean the chamber. The weak acid may be a dilute phosphoric acid, for example, a solution containing about 5% phosphoric acid by volume, or it could be another acid for example hydrochloric acid at a similar strength. The valve means could also be configured to switch the supply between just untreated fluid and weak acid.

[0020] Preferably, the source chosen by the valve means is controlled by the control means.

[0021] Providing the transmission meter with an inlet which can be switched between two or more supplies allows the transmission meter to be cleaned, calibrated etc without the need to disassemble the system. Therefore, in a second aspect, the present invention provides a meter for measuring a fluid, the meter comprising a

chamber for the passage of fluid therethrough, sensor means for detecting a parameter within the chamber and means for switching the type of fluid which flows through the chamber dependent on the parameter detected by the sensor means.

5 [0022] The sensed parameter can be the fluid transmittance, the irradiation from a radiation source located within the chamber etc. The different types of fluid may be chosen from the fluid which is to be measured in the chamber, a reference fluid, (for example, pure water), which can be used to calibrate the system or a cleaning fluid (for example, an acid). The meter can be used to measure any property of the fluid, for example, the transmittance, flow rate etc.

10 [0023] Preferably, the purification chamber also comprises cleaning means for cleaning the chamber. These cleaning means may be provided by a mechanical system which operates on a fixed time cycle. These cleaning means may be controlled by software which is used to detect when the UV level within the chamber falls below a certain limit. These cleaning means may also be controlled by the control means.

15 [0024] Preferably, the apparatus further comprises a flow meter such that the rate of fluid flow through the purification chamber and the transmission meter can be monitored.

20 [0025] Above, the disinfection apparatus has been described as having two chambers, an analysis chamber and a purification chamber. However, the analysis of the transmittance of the fluid under treatment could be performed within the purification chamber.

25 [0026] Therefore, in a fourth aspect the present invention provides a disinfection apparatus comprising a purification chamber having means to receive an electromagnetic source for purifying liquid passed through said purification chamber, the apparatus further comprising three sensors each configured to measure the output from said source, wherein each of the three sensors are located at different distances from the source.

30 [0027] Typically, the purification chamber will have a plurality of sources. Preferably, to obtain consistent results, the three sensors will measure the output from the same electromagnetic source. Even more preferably, from the same part of the source.

35 [0028] In a fifth aspect, the present invention provides a method for measuring the transmittance of a fluid, the method comprising the steps of:

40 [0029] passing the fluid between an electromagnetic source and three sensors configured to measure the output from said source, wherein each of the sensors are located at different distances from said source; and
45 measuring the output of the source using each of the three sensors.

50 [0029] The present invention will now be described with reference to the following preferred non-limiting

embodiments in which:

Figure 1 shows a transmission meter in accordance with an embodiment of the present invention;

Figure 2 shows a sectional view of the transmission meter of Figure 1;

Figure 3 shows a water disinfection system incorporating the embodiment of Figure 1;

Figure 4 shows a further embodiment of the present invention where the transmission meter is *in-situ* in a purification chamber;

Figure 5 shows an example of a sensor which may be used in accordance with an embodiment of the present invention; and

Figure 6 shows a valve arrangement in accordance with a preferred embodiment of the present invention.

[0030] The transmission meter of Figure 1 has a cylindrical chamber 1 through which the fluid to be treated is passed. The fluid will typically be water, but other fluids could be used. The fluid can flow through the chamber 1 either continuously or intermittently. The chamber 1 has an inlet pipe 3 and an outlet pipe 5 to allow the flow of fluid through the chamber 1. The outlet pipe 5 is situated on the upper side of the chamber 1 as this avoids problems due to trapped air. The chamber 1 is made from a corrosion resistant material such as stainless steel and is designed to withstand the maximum pressure to which the meter will be connected. The diameter of the chamber will typically be about 0.2m.

[0031] An elongate fused silica sleeve 9 is located within the chamber 1. The sleeve 9 is orientated parallel to the central symmetry axis of the cylindrical chamber, and to one side of the central axis.

[0032] The meter will ideally operate without maintenance for a period of about 12 months. Therefore, a suitable source which can operate under these conditions should be chosen. The UV source used in most laboratory spectrophotometers is a Deuterium lamp which has a stable continuous output between 200nm and 400nm. These lamps tend to be expensive and have a short operating time of between 1000 to 2000 hours. The preferred source is a low pressure mercury discharge lamp. These emit a spectral line at 253.7 nm. These are low cost lamps with a long operating life. However, their output changes with temperature and time.

[0033] A UV source 7, which will typically be an 8-watt Sankyo Denki UV lamp, is located within the sleeve 9 to form a sleeve and source assembly 8. The lamp irradiates at 253.7 nm. The sleeve and source assembly 8 is inserted into chamber 1 via port 11 which is located on the outlet side 5 side of the chamber 11. The lamp 7 and

sleeve 9 may be separated from each other. However, typically, the lamp and sleeve are a single assembly.

[0034] Three sensors, D1, D2 and D3 are located in a plane perpendicular to the symmetry axis of the chamber 1 and about the circumference of chamber 1. As the source 7 is placed off-centre in the chamber 1, each of the sensors is disposed at a different distance from the source 7.

[0035] Ideally, the transmittance of the fluid should be measured across the germicidal range which is from 240nm to 280nm. However, it is generally accepted that a measurement at 254 nm (which is consistent with the preferred UV source) is adequate.

[0036] Figure 2 shows a section through the cylindrical chamber 1, taken through the plane of the sensors D1, D2 and D3. Sensor D1 is closest to the source 7 and is at distance "a" away from the circumference of the sleeve 9. Sensor D2 is slightly further away from the source than sensor D1 and is at distance "b" from the sleeve 9. Sensor D3 is at distance "c" from the sleeve and is the furthest sensor from the source 7. The radius of the sleeve 9 is "r".

[0037] The distances a, b and c are determined by the exact position of the sensors on the circumference of the chamber and the position of the source 9 in the chamber. The source 9 and sensors D1, D2 and D3 will be arranged to allow a significant difference between distances a, b and c. Typically, b and c will be n multiples of a, where n is an integer of 2 or more. In a chamber with a diameter of about 0.2m, a will be about 0.04m, b will be about 0.08m and c will be about 0.12m.

[0038] The optimum lengths of distances a, b and c will depend, to a certain extent, on the transmissivity of the fluid to be measured. In water of a reasonably high quantity, the smallest path length will be about 4cm. In poor quality fluids, the smallest path length should ideally be about 1 cm. For example, for a fluid with a low transmissivity, a, b and c will typically be 1cm, 2cm and 3cm. This would require a chamber diameter of about 5cm.

[0039] Assuming that the UV power which is outputted by the source is "P", the length of the UV source is "L", the transmittance of the fluid under test is "T% per metre" and that the attenuation due to deposition on optical surfaces is "K", the following simplified relations can be derived for the intensity of light H measured at sensors D1, D2 and D3

$$50 \quad \text{Intensity at D1} = H_1 = \frac{P}{2\pi L(a+r)} \cdot K \cdot T^a$$

$$55 \quad \text{Intensity at D2} = H_2 = \frac{P}{2\pi L(b+r)} \cdot K \cdot T^b$$

$$55 \quad \text{Intensity at D3} = H_3 = \frac{P}{2\pi L(c+r)} \cdot K \cdot T^c$$

[0040] By dividing the above 3 equations, it is possible

to eliminate the non-linear term "K":

$$\frac{H_2}{H_1} = \frac{(a+r)}{(b+r)} \cdot T^{(b-a)}$$

$$\frac{H_3}{H_1} = \frac{(a+r)}{(c+r)} \cdot T^{(c-a)}$$

$$\frac{H_3}{H_2} = \frac{(b+r)}{(c+r)} \cdot T^{(c-b)}$$

a, b and c are easily measurable. For this example, it will be assumed that a = 2a and c = 3a. In this situation, the following equations are derived:

$$T^{(a)} = \frac{H_2}{H_1} \cdot \frac{(2a+r)}{(a+r)} = \frac{H_2}{H_1} \cdot k_1$$

$$T^{(a)} = \sqrt{\frac{H_3}{H_1} \cdot \frac{(3a+r)}{(a+r)}} = \sqrt{\frac{H_3}{H_1} \cdot k_2}$$

$$T^{(a)} = \frac{H_3}{H_2} \cdot \frac{(3a+r)}{(a+r)} = \frac{H_3}{H_2} \cdot k_3$$

where k_1 , k_2 and k_3 are dimensionless constants.

[0041] From these calculations, it is seen that the transmittance of the fluid can be derived from three separate calculations using the intensity measurements H_1 , H_2 , H_3 .

[0042] It is also evident that the three distances a,b,c should ideally be significantly different to enable the effects of attenuation due to deposition on the optical surfaces and variation of UV source output to be eliminated.

[0043] The above analysis has been simplified to illustrate how the transmittance of the fluid can be derived. In practice, the above equations for H_1 , H_2 , H_3 may contain a more complex algorithm, however any errors due to simplification are of second order and can be easily corrected in the remote analyser.

[0044] In practice, the transmission meter of Figure 1 will be primarily used in combination with a water disinfection system such as that shown in Figure 3. The meter will be placed upstream of the purification chamber, such that the transmittance of the water to be treated is measured.

[0045] The system comprises a purification chamber 21 which has an inlet pipe 23 and an outlet pipe 25 for ensuring the flow of water through the purification chamber 21. The inlet pipe 23 carries untreated water into the purification chamber 21. The purification chamber 21 comprises at least one UV light source similar to that described in relation to Figure 1. The UV light source is

used to purify the water. As a high power is required to disinfect the large volume of water in the chamber 21, there will often be a plurality of UV light sources in each purification chamber 21. Typically, the purification chamber 21 will be cylindrical with a diameter from 0.2m to 0.5m and a length from 1m to 1.5m.

[0046] The purification chamber will also have at least one UV sensor 37 (which is similar to sensors D1, D2 and D3). This will be described in more detail with reference to Figure 5. The UV sensor 37 is used to measure the germicidal UV intensity within the purification chamber 21. Typically, a UV sensor will be provided for each UV source.

[0047] A flow meter 33 is provided on inlet pipe 23. The inlet 23 has a branch 29 located upstream from the flow meter 33 which takes untreated water to valve 31. Providing that valve 31 is set to an appropriate setting, the water from branch pipe 29 flows into transmission meter 1 for measurement.

[0048] Water which has passed through transmission meter 1 is taken back into the inlet pipe 23 by pipe 34. Pipe 34 joins the inlet pipe 23 upstream from the purification chamber 1, but downstream from flow meter 33.

[0049] The disinfection apparatus comprises a control means provided by a processor 27. The processor is used to process data from the transmission meter 1, the purification chamber 21 and also data from flow meter 33. The processor 27 may take the output directly from sensors D1, D2 and D3 (as shown in the Figure). Alternatively, the output from sensors D1, D2 and D3 may be analysed prior to entering to processor 27 so that processor 27 receives a signal from the transmission meter 1 which is related to the transmittance of the fluid to be treated.

[0050] The processor 27 takes the output from the UV sensor 37 in the purification chamber 21 via input channel A and it takes the output from the flow meter 33 via input channel B.

[0051] Using the data from these inputs and the data from the transmission meter 1, the processor can fully monitor the disinfection system. Further, the processor can be used to control various parts of the system depending on the data received.

[0052] In order to ensure that the correct treatment levels for the water are used, the processor 27 can increase the power supplied to the UV source within purification chamber 21. Often, a plurality of purification chambers 21 are provided in parallel. The inlet to each purification chamber has a valve. The processor 27 controls these valves such that the number of purification chambers in use at any one time can be automatically controlled dependent on the inputs received by processor 27.

[0053] In Figure 3 the flow of untreated water into the transmission meter 1 is controlled via valve 31. Valve 31 is connected to untreated water pipe 29, it is also connected to de-ionised water supply 35, such that the flow of fluid into the transmission meter 1 can be switched

between untreated water and de-ionised water. De-ionised water has a transmittance of close to 100%. Therefore, switching the fluid supply to de-ionised water will allow the processor to send a command to re-calibrate the sensors of the transmission meter.

[0054] In figure 3, the processor 27 only has an output to valve 31. However, processor 27 can also be used to control a cleaning operation of the meter 1. This will be described in more detail with reference to Figure 6. Further, the processor 27 could also be used to control the purification chamber itself. For example, it could be used to instruct a cleaning operation of the chamber, or it could be used to reduce the flow of untreated water into the chamber 21 if the power of the UV sources are starting to decrease etc. The processor can also be used to turn off the source of electromagnetic irradiation inside the meter 1, in order to set a zero reference for the three sensors D1, D2 and D3.

[0055] In the arrangement of Figure 3, the meter is separate from the purification chamber 21. In Figure 4, the transmission meter 1 is provided *in-situ* in the purification chamber 21. Sensors D1, D2 and D3 are located around the circumference of the purification chamber 21 and at different distances from source 41. The same calculation can thus be carried out by taking the readings from sensors D1, D2 and D3 as explained in relation to figures 1 and 2.

[0056] Figure 5 is a schematic of a preferred sensor assembly which can be used for sensors D1 to D3 or sensor 37 on the purification chamber. The sensor has a main body 51 and a connecting collar 53. The connecting collar 53 is used to connect the sensor to the side of chamber 1 or purification chamber 21.

[0057] UV light from the source inside the chamber 1,21, is detected by fused silicon probe 55 which is located within connection collar 53. The output from the fused silicon probe 55 is passed through an attenuation filter 57 and onto first mirror 59 which is located within the body 51 of the sensor. First mirror 59 has a coating which allows the mirror to only reflect light within a certain wavelength range. The reflected light is then passed through a second attenuating filter 61.

[0058] The light which passes through filter 61 is reflected off second mirror 63 which is also configured only to reflect light within a certain wavelength range. Typically, the wavelength range for both of the first and second mirrors will be from 240 to 280nm. The light is then reflected onto photo-diode 65 which outputs an electric signal dependent on the intensity of radiation incident on the photo-diode. The electric signal is then fed into signal box 67 for amplification and conditioning of the signal. This electrical signal is then fed out of main body 51. The signal may be analogue or digital.

[0059] As has previously been mentioned, the processor 27 can be used to control the cleaning of the transmission meter 1. A possible arrangement for achieving this is shown in Figure 6. To avoid unnecessary repetition, like numerals from Figure 3 will be used to denote

like features in Figure 6.

[0060] Untreated water is fed through branch pipe 29 to valve 31. If valve 31 is open to line 29 then untreated water will be fed into the transmission meter 1 as described with reference to figure 3. If valve 31 is not open to line 29 but is instead open to line 51, secondary valve 53 which is located on line 51 determines the type of fluid which will flow into the transmission meter 1. Secondary valve 53 can either allow dilute acid to pass from line 55 through pump 57 into valve 53 and hence into the transmission meter 1 via valve 31 and line 51. Or, valve 31 may allow de-ionised water from line 59 through pump 61 to pass into the transmission meter 1. The dilute acid can be used to clean the system as it will dissolve much of the scale which will accumulate within the transmission meter. The water can then be used to re-calibrate the system as previously described.

[0061] Once the water has passed through the transmission meter 1, it is fed into outlet valve 63. Outlet valve 63 will either let the fluid be passed back into line 34 and hence into inlet pipe 23. Alternatively, valve 63 can direct water or dilute acid down line 65 into the drain. If the transmission meter 1 is being washed with acid, obviously, it is desirable if the valve 63 directs the acid into the drain.

Claims

1. A transmission meter (1) for measuring the transmittance of a fluid, the meter (1) comprising an analysis chamber for passage of the fluid therethrough and means for receiving an electromagnetic source (9) within said chamber, **characterised in that** the meter further comprises three sensors (D1, D2 and D3) each configured to measure the output from said source (19), wherein each of the three sensors (D1, D2 and D3) are located at different distances from the source (19).
2. A meter according to claim 1, further comprising analysis means for comparing the outputs from each of the sensors (D1, D2, D3) to determine the transmittance of the fluid.
3. A meter according to either of claims 1 or 2, wherein the sensors (D1, D2, D3) are arranged to detect the output from the same part of the said source (9).
4. A meter according to any preceding claim, wherein the distances of the two sensors (D2, D3) which are furthest from the source are substantially integral multiples of the distance of the closest sensor (D1) to the source.
5. A meter according to any preceding claim, further comprising valve means (31) configured to switch the supply of fluid to the analysis chamber between

at least two sources (29, 35).

6. A meter according to claim 5, wherein the valve means (31) is configured to switch the supply between at least three different sources (29, 55, 59). 5

7. A meter according to either of claims 5 or 6, wherein at least one of the sources (35) is a de-mineralised water source for calibration of the meter. 10

8. A meter according to any of claims 5 to 7, wherein at least one of the sources (55) is an acid source for cleaning the apparatus.

9. A meter according to any of claims 5 to 8, the meter further comprising control means (27) for determining the supply of fluid into the analysis chamber. 15

10. A disinfection apparatus comprising a meter (1) according to any preceding claim, and a purification chamber (21), said purification chamber (21) being capable of receiving an electromagnetic source for purifying liquid passed through said purification chamber (21). 20

11. An apparatus according to claim 10, wherein the fluid which is to be purified is fed into the purification chamber (21) via an inlet pipe (23) and a fraction of the fluid in this pipe is fed into the analysis chamber. 25

12. An apparatus according to claim 11, wherein fluid which exits the analysis chamber is fed back into the said inlet pipe (23). 30

13. A disinfection apparatus comprising a purification chamber (21) having means to receive an electromagnetic source (41) for purifying fluid passed through said purification chamber (21), characterised in that the apparatus further comprises three sensors (D1, D2, D3) each configured to measure the output from said source (41), wherein each of the three sensors (D1, D2, D3) are located at different distances from a source (41) in said purification chamber (21). 35

14. An apparatus according to any of claims 10 to 13, wherein a further UV sensor (37) is located in said purification chamber (21). 40

15. An apparatus according to any of claims 10 to 14, wherein the apparatus further comprises a flow meter (33) for measuring the flow of fluid into the purification chamber (21). 50

16. An apparatus according to any of claims 10 to 15, wherein the output from the sensors (D1, D2, D3) is fed into a control means (27) and said control means is capable of initiating corrective action in 55

said purification chamber (21).

17. A meter for measuring a fluid, the meter comprising a chamber for the flow of fluid therethrough, sensor means (D1, D2, D3) for measuring a parameter within the chamber and means for switching (27) the type of fluid which flows through the chamber depending on the parameter detected by the sensor means.

18. A method for measuring the transmittance of a fluid, characterised in that the method comprises the steps of:

passing the fluid between an electromagnetic source (9) and three sensors (D1, D2, D3) configured to measure the output from said source (9), wherein each of the sensors (D1, D2, D3) are located at different distances from said source; and

measuring the output of the source using each of the three sensors.

Fig.1

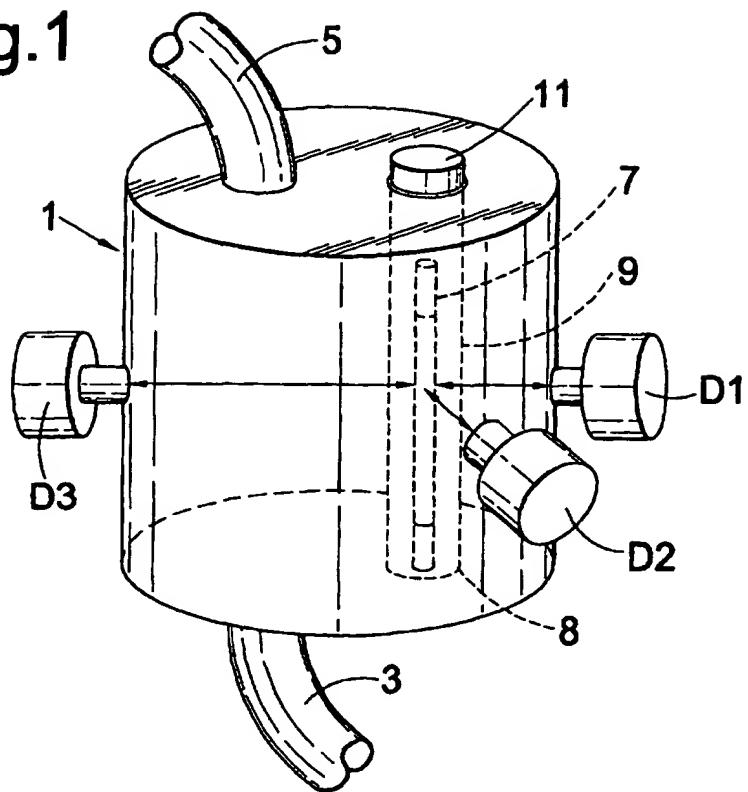
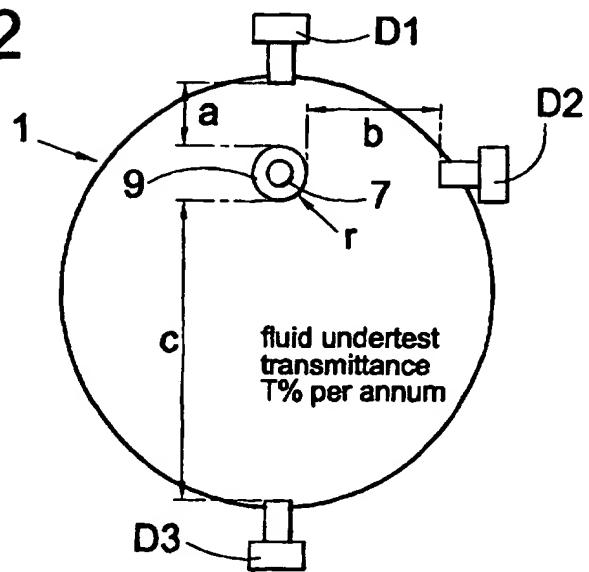


Fig.2



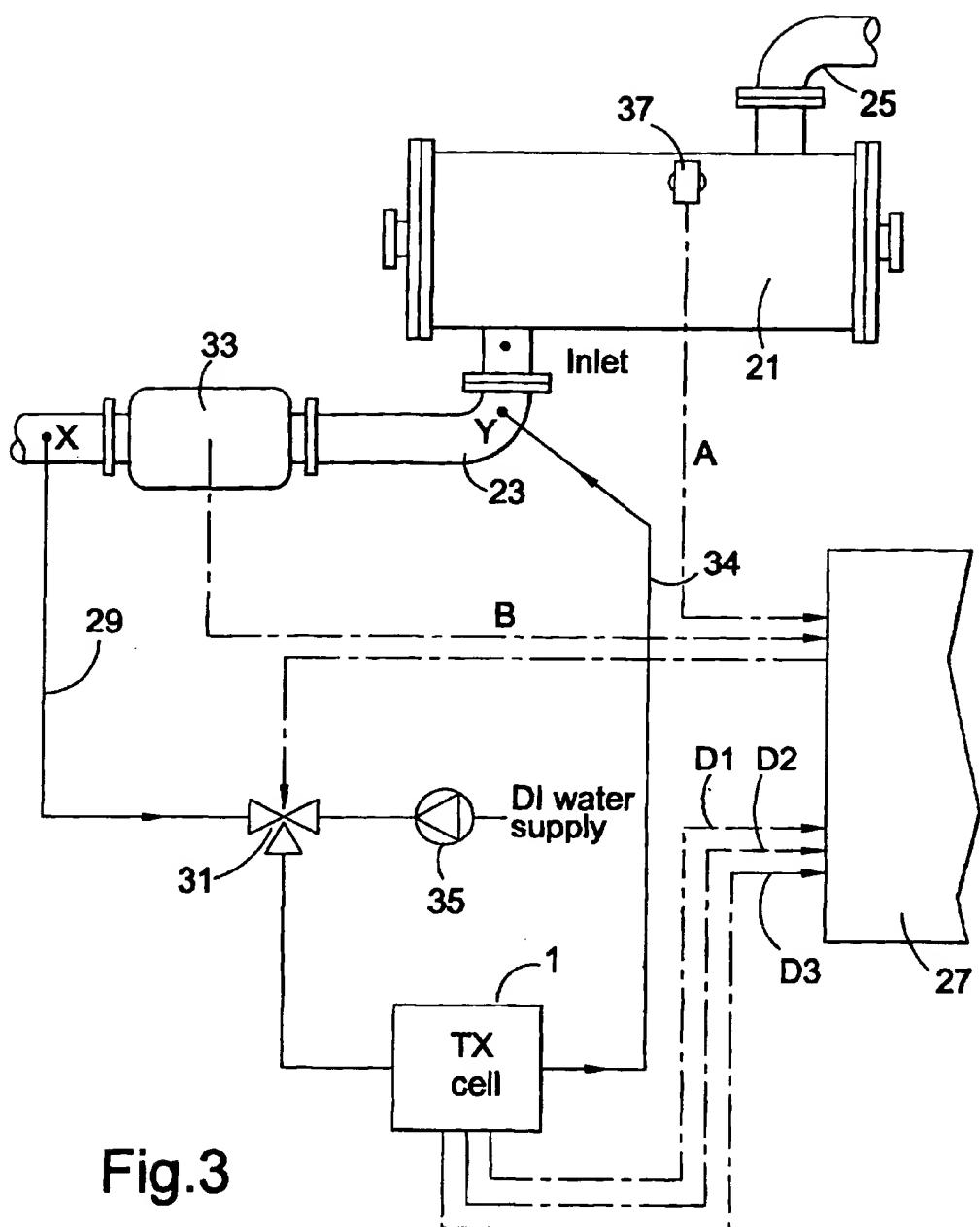


Fig.3

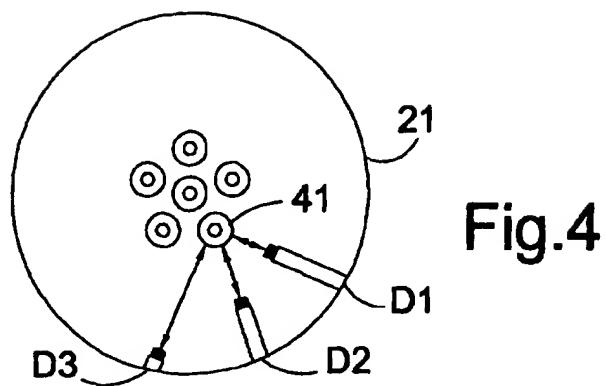


Fig.4

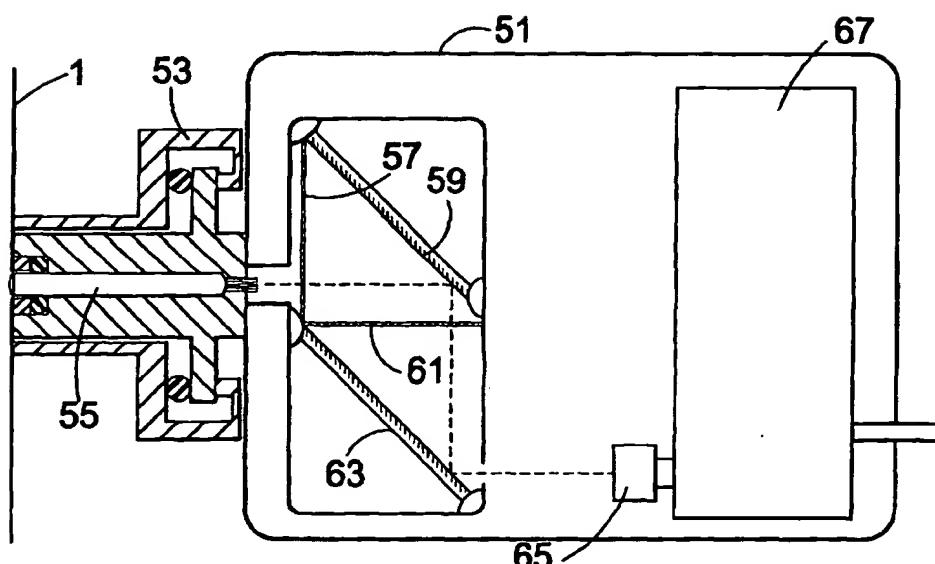


Fig.5

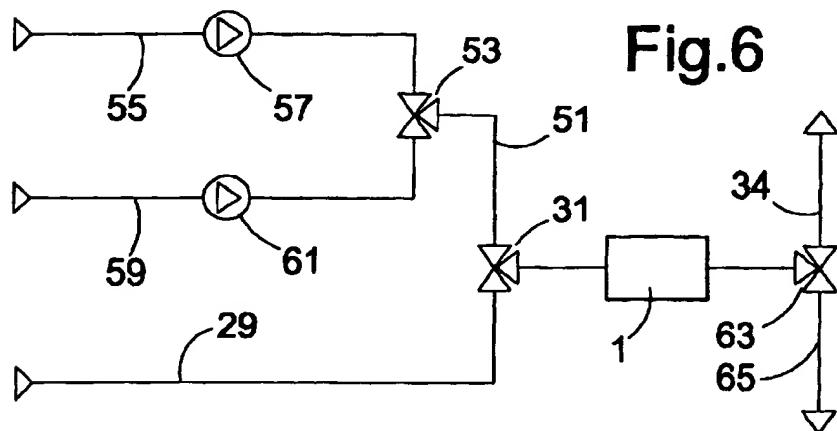


Fig.6



European Patent
Office

EUROPEAN SEARCH REPORT

Application Number
EP 00 30 1783

DOCUMENTS CONSIDERED TO BE RELEVANT			CLASSIFICATION OF THE APPLICATION (Int.Cl.7)										
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim											
D, X	NL 1 003 961 C (BERSON MILIEUTECHNIEK BV) 6 March 1998 (1998-03-06)	1-4, 10-16, 18	G01N21/53 C02F1/32										
Y	* page 3, line 24 - line 33 * * page 5, line 20 - line 23 * * page 7, line 10 - line 13 *	5-9											
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